

Teffil™ HF

High Flow PTFE
Membrane Filters



Teffil™ HF is a range of fully optimised high flow PTFE membrane filters with PFA supports. These cartridge filters are suitable for use within a number of chemical applications including organic stripper, IPA and other solvent recirculation bath applications.

This chemically inert filter range offers the removal of fine particulate from 0.05-5 micron in challenging operating conditions.

Typical Applications

- Aggressive chemicals
Chemical delivery system filtration of strong acid base solution.
- Solvents
UHP solvent treatment for bumping stripper.
- High purity chemicals

Features and Benefits

- Excellent flow characteristics
- Full traceability
- Controlled manufacturing environment
- Fast rinse up time
- Low binding and fouling

Ordering Information

Product Code: **X - X - X - X - X - X**

Series	Pore rating (µm)	Version	Length	Adaptor	Seals
FL Teffil™	P5 0.05	H High Flow	04 102mm (4")	A Code 3	A EPDM
	10 0.1		1 250mm (10")	*Other options available on request.	B Silicone
	20 0.2		2 510mm (20")		C Viton®
					K FEP/FKM

Specifications

Materials of Manufacture

Filtration media: membrane	Hydrophobic PTFE
End caps:	PFA
Centre core:	PFA
Outer hardware:	PFA
Gaskets/O-rings:	PFA encapsulated FKM

Cartridge Dimensions (Nominal)

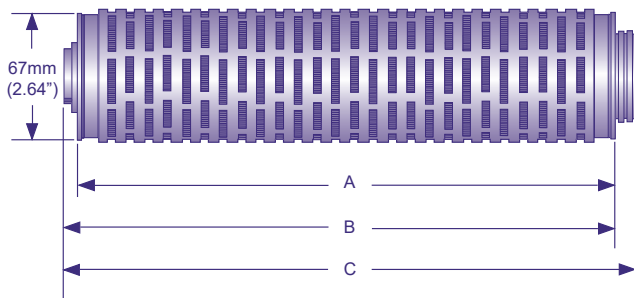
Diameter: 67mm (2.6")
Length: 254mm (10")

Pore Size Rating

0.05, 0.1, 0.2, 0.45, 1 and 5 microns.

Dimension Specifications

Length (inch)	A	B	C
4	105mm +/-2	110mm +/-2	128mm +/-2
10	237mm +/-2	242mm +/-2	261mm +/-2
20	463mm +/-3	468mm +/-3	486mm +/-3



Total metals (13 elements, ICP-MS)	UHP < 25 ppb / device Ultra low metal < 10 ppb / device
Particle shedding cleanliness	< 5 particles / 1ml ≥ 0.15µm @10LPM UPW flow
TOC recovery (per 10" equivalent)	< 5ppb of feed DI water after 120L @ 5LPM
Resistivity recovery (per 10" equivalent)	< 0.5MΩ of feed DI water after 120L @ 5LPM

Differential Pressure

Maximum forward differential pressure:
5.1bar (75psi) @ 25°C (77°F)
5.1bar (75psi) @ 120°C (248°F)

Operating Temperature

Maximum operating temperature:
180°C (356°F) at the above conditions.

Metallic Cleanliness

<25µg per device. Ultra-high-purity.

Flow Rates

